

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>09/988,122</u>	Prepared by <u>CH</u>	Tracking Number <u>05889446</u>	
Examiner-GAU <u>Booth-2812</u>	Date <u>2/10/04</u>	Week Date <u>1/12/04</u>	
	No. of queries <u>1</u>	IFW	

JACKET

a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. <u>PTO-1449</u>
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

SPECIFICATION

- a. Page Missing
- b. Text Continuity
- c. Holes through Data
- d. Other Missing Text
- e. Illegible Text
- f. Duplicate Text
- g. Brief Description
- h. Sequence Listing
- i. Appendix
- j. Amendments
- k. Other

CLAIMS

- a. Claim(s) Missing
- b. Improper Dependency
- c. Duplicate Numbers
- d. Incorrect Numbering
- e. Index Disagrees
- f. Punctuation
- g. Amendments
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- k. Other

MESSAGE

1449- Please either
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Please supply.

Thank you
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RESPONSE

initials

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
P-4007-USAPPLICATION NO.
09/988,122INFORMATION DISCLOSURE
STATEMENT BY APPLICANT

MAY 09 2002

APPLICANTS
Bloom et al.CONFIRMATION NO.
8188FILING DATE
11/19/01GROUP
2818

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
	EP 0751560	01/02/1997	Europe				
	EP 1073120	01/31/2001	Europe				
	GB 1297899	11/29/1972	Great Britn				
	GB 2157489	10/23/1985	Great Britn				
	JP 05021758	01/29/1993	Japan				
	JP 07193151	07/28/1995	Japan				
	JP 09162314	06/20/1997	PCT				
	WO 81/00790	03/19/1981	PCT				
	WO 96/25741	08/22/1996	PCT				

EXAMINER

DATE CONSIDERED

11/13/03

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not conformance and not considered. Include copy of this form with next communication to applicants.